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EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
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EXAMINER INITIAL		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES NO
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	AK						
	AL						

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MD	AM	"Hydrogen silsesquioxane/novolak bilayer resist for high aspect ratio nanoscale electron-beam lithography," Falco et al. *J. VAc. Sci. Technol. B.*, Nov./Dec. 2000.
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EXAMINER	DATE CONSIDERED
Deborah Chacko-Davis	03/02/06

EXAMINER: **Initial if citation considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.**